BONDING STUDIES OF COMPOUNDS OF BORON AND THE GROUP IV ELEMENTS VI. MASS SPECTROMETRIC STUDIES ON COMPOUNDS Me₄M AND

 $Me_3M-M'Me_3$ (M AND M'=C, Si, Ge, Sn, AND Pb): THERMOCHEMICAL DATA

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SUMMARY

The mass spectra of the series of compounds $Me_3M-M'Me_3$ and Me_4M are reported and analysed, where M and M' are C, Si, Ge, Sn, and Pb. Ionisation potentials of the parent molecular ions and appearance potentials of Me_3M^+ and $Me_3M'^+$ fragment ions have been measured. Using known or estimated values for the gas phase standard enthalpies $[\Delta H_f^0(g)]$ of formation of Me[•], $Me_3C^{•}$, Me_3C^+ , Me_4M , Me_6C_2 , Me_6Si_2 , and Me_6Sn_2 yields an overdetermined set of 31 simultaneous equations for the $\Delta H_f^0(g)$ of 27 molecules, radicals, and ions. A least squares analysis thus affords the $\Delta H_f^0(g)$ data for all the species $Me_3M-M'Me_3$, Me_4M , $Me_3M^{•}$, and Me_3M^+ . From these data, values are derived for bond (D) and mean bond (\overline{D}) dissociation energies : $D(Me_3M-Me)$, $D(Me_3M-M'Me_3)$, and $\overline{D}(Me_4M)$, as well as mean thermochemical bond energy terms (\overline{E}) for Me-M and M-M' bonds in each of these species. Data (in kcal/mole) include

(i). \overline{E} (Me-M) in Me₄M (value for M in parentheses): 82.1(C), 68.5(Si), 59.9(Ge), 48.1(Sn), and 32.9(Pb);

(ii). E(M-M') in Me_6M_2 : 78.9(C), 68.0(Si), 59.3(Ge), 38.3(Sn), and 33.3(Pb); (iii). E(M-C) in Me_3M-CMe_3 : 66.6(Ge), 53.0(Sn), and 41.6(Pb); (iv). E(M-Si) in $Me_3M-SiMe_3$: 63.3(Ge) and 56.1(Sn), and

(v). E(Ge-Sn) in Me₃Ge-SnMe₃: 53.7.

Trends are discussed.

INTRODUCTION

Published values for the ionisation potentials of Me_3M^* radicals are listed in Table 1. The considerable disagreements are doubtless in part due to the variety of techniques employed by different workers. In this study, an attempt has been made to obtain self-consistent values by using a single technique for all our experimental measurements, and to obtain sufficient data to provide an internal check on the results. One of the aims of this work was to provide reliable thermochemical data on organometallic compounds of the Group IV elements, which have been notably lacking¹⁰.

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TABLE 1

Radical IP (eV) Method" Ref. Mc₃C^{*} 7.42 ± 0.07 Α 1 7.45±0.1 В 2 6.9 ± 0.1 С 3 С Me₃Si. 7.10 ± 0.15 4 6.94±0.43 С 5 D 6 7.8 7.97 ± 0.10 С 9 Me₃Ge^{*} 8.0 D 6 С 7 Me₃Sn⁻ 6.54±0.15 С 6.80 ± 0.3 8 7.10 ± 0.05 В 2 D 7.6 6

D

IONISATION POTENTIALS OF THE Me3M RADICALS

^a A: Pyrolysis to produce Me_3C radicals in the mass spectrometer; B: Me_3M radicals produced and ionised in a double-beam mass spectrometer; C: combination of thermochemical and mass spectrometric data; D: not stated (these values were quoted without references or probable errors).

6

EXPERIMENTAL

7.6

Me₁Pb.

The hexamethyl compounds were, in the main, prepared by the general reaction of eqn. (i), while in one case the procedure of eqn. (2) was used.

$$Me_3MLi + Me_3MX \xrightarrow{THF} Me_3M - M'Me_3 + LiX$$
 (1)

The compounds Me_6Si_2 , Me_6Ge_2 , and Me_6Sn_2 were gifts from other workers in this laboratory, and Me_6C_2 was obtained from the Aldrich Chemical Co.

$$Me_{3}SiCl + Me_{3}GeBr \xrightarrow{\kappa} Me_{3}Si-GeMe_{3} + Me_{6}Si_{2} + Me_{6}Ge_{2}$$
(2)

The tetramethyl compounds were prepared by standard literature methods¹¹, except for neopentane, which was a gift from Dr. J. E. Drake.

All the compounds, except Me_4C , Me_6C_2 , and Me_3Si -GeMe₃, were purified by distillation under reduced pressure. The hydrocarbons were used without further purification.

The silicon-germanium compound was purified by preparative scale GLC. Purity was verified by elemental analyses (C and H), b.p. (or m.p.), and comparison of IR spectra with those of authentic specimens.

Samples of the hexamethyl compounds were introduced into the A.E.I. MS9 mass spectrometer by evaporation through an all-glass "direct-inlet" probe¹². Convenient ion currents were obtained by immersing the samples in slush baths. The tetramethyl compounds were introduced via the gas (cold) inlet. The spectra of all the compounds studied were recorded using a 50 eV electron beam, 8 kV accelerating voltage, and a source temperature of 80–100°. The relative abundances of "mono-isotopic" species were calculated by standard procedures^{13,22}. The isotopic abun-

dance values used for the combinations Si-Ge, Ge-Sn¹⁴, Ge-Ge¹⁵, and Sn-Sn¹⁶ were those reported in the literature. The abundances of the lead isotopes in the lead-containing compounds were calculated from the mass spectrum of Me₄Pb. These values and the values used for Si-Si and Si-Sn combinations are shown in Table 2.

TABLE 2

ISOTOPIC ABUNDANCES IN Pb, Si2, AND SiSn CONTAINING COMPOUNDS

Normal m/e	Abundance (%)	No. of combinations contributing of peak
Pb Compounds		
204	1.34 <u>+</u> 0.06	
206	16.12 ± 0.08	
207	21.03 ± 0.08	
208	51.51 ± 0.09	
Si ₂ Compounds		
56	85.2	1
57	8.6	2
58	5.8	3
59	0.3	2
60	0.1	I
SiSn Compounds		
140	0.8	1
141		1
142	0.6	2
143	0.3	2
144	13.0	3
145	7.7	3
146	22.5	3
147	9.1	3
148	32.6	3
149	1.8	2
150	5.3	2
151	0.2	1
152	5.6	2
153	0.3	1
154	0.2	1

The ion abundances of the tetramethyl compounds agree reasonably well with the results of Dibeler¹⁷, and therefore are not listed here. The ion abundances for the hexamethyl compounds are shown in Table 3. Major metal-containing ions of >1% of the total ion abundance are listed; the abundance of the C₄H₉⁺ ion from the t-butyl compounds, and the other major hydrocarbon ions from Me₆C₂, are also given.

For ionisation and appearance potential measurements, the mass spectrometer was operated as described previously¹⁸, except that the electron-trap voltage was left unaltered. The heliopot controlling the electron-beam energy was coupled to the photographic recorder so that the appearance of an ion was recorded automatically¹⁹. The appearance and ionisation potential measurements were interpreted by the

Ion	M-M'		•							<u>*</u> _	
(ampostave)	C–C	C-Ge	C-Sn	C-Pb	Si-Si	Si-Ge	Si–Sn	Ge-Ge	Ge-Sn	Sn-Sn	Pb–Pb
C ₆ H ₁₈ MM'		4	3	1	12	8	5	7	3	5	2
C ₅ H ₁₅ MM'	3	6	5	3	20	19	19	18	15	16	12
C ₄ H ₁₂ MM'					1	1	2	1	2	2	2
C ₃ H ₉ MM'	1					1	1	2	2	1	2
C₂H₅MM′								1	1	1 .	1
C ₂ H ₅ MM′								1	1	1	1
CH ₃ MM'	2								1	i	3
CH ₂ MM'										1	1
MM'										2	6
$C_{3}H_{10}M$	2										
C₃H₀M	44	10	23	32	42	35	33	57	33	46	38
C ₃ H ₈ M	12										
C ₃ H ₇ M	2										
C ₂ H ₇ M	6				3	1	1	2	3	1	
C₂H ₆ M	1				5	1		2	1	4	3
C ₂ H ₅ M	13										
CH3M	7				9	3	5	1	- 1	1	
CH₄M	2				2						
CH ₃ M	3				6	1	2	7	6	15	23
H ₃ M	2										
HM							1	1	1	1	
М										2	6
C ₃ H ₉ M′		65	48	35		8	5		7		
C₂H ₇ M′		1	1	1		1					
C ₂ H ₆ M′		2	3	4		8	7		8		
CH₅M'		1				1					
CH₃M′		6	11	16		12	18		15		
CH₂M′		2	1	1							
HM'		2	2	1							
M′		1	3	6			1				

TABLE 3

ION ABUNDANCES FOR IONS FROM HEXAMETHYL COMPOUNDS

Lossing semi-logarithmic plot method²⁰. The results for Me_3C -Sn Me_3 were also calculated by the extrapolated voltage difference method²¹. Agreement between the two methods was well within experimental error. The ionisation and appearance potentials, and the slush bath temperature used are given in Table 4. Each quoted error represents twice the standard deviation of the mean of the number of measurements also quoted.

DISCUSSION

Mass spectra

In all spectra the ion $C_3H_9M^+$ was the most abundant species. The stability of these ions is associated with their having an even number of electrons and being isoelectronic with the neutral stable Group III molecules; this has been discussed by several authors^{22,23}. It is assumed that these ions have structures comparable to the

TABLE	4 ª
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Compound	Slush bath		No. of	IP (eV)	AP (eV)		
	(°C)		readings		Me ₃ M ⁺	⁺ M'Me ₃	
Me ₃ C-GeMe ₃		-78	7	8.98±0.12	10.19±0.27	9.91 ± 0.22	
Me ₃ C-SnMe ₃		-45	7	8.34 ± 0.11	10.03 ± 0.23	9.32±0.16	
Me ₃ C-PbMe ₃	-34,	-23	7	7.99 <u>+</u> 0.13	9.45 ± 0.15	8.67 ± 0.21	
Me ₃ Si-SiMe ₃		-84	8	8.35+0.12	10.22+0.18		
Me ₃ Si-GeMe ₃		-78	7	8.31 ± 0.10	10.19 ± 0.12	9.99+0.14	
Me ₃ Si-SnMe ₃	-78,	-45	7	8.18 ± 0.14	10.18 ± 0.26	9.80 ± 0.24	
Me ₃ Ge-GeMe ₃	•	-64	7	8.18 ± 0.11	9.96 ± 0.16		
Me ₃ Ge-SnMe ₃		-45	7	8.20 ± 0.10	10.01 ± 0.18	9.85±0.22	
Me ₃ Sn-SnMe ₃		-45	9	8.02 ± 0.15	9.51 ± 0.22		
Me ₃ Pb-PbMe ₃		-23	7	7.41 ± 0.10	9.02 ± 0.14		
Me ₃ Si-Me			7	9.85+0.16	10.53±0.20		
Me ₃ Ge-Me			7	9.29 ± 0.14	10.05 ± 0.14		
Me ₃ Sn-Me			7	8.76 ± 0.12	9.58 ± 0.19		
Mc ₃ Pb-Me			7	8.26 ± 0.17	8.77 ± 0.16		

IONISATION AND APPEARANCE POTENTIALS OF Me3M-M'Me3 AND Me3M-Me COMPOUNDS

^a Tolerances are shown as $\pm 2 \times$ standard deviations.

t-butyl carbonium ion, which is known to be particularly stable ^{3,24}. This assumption cannot be proved, but other possible structures, such as carbonium ions of the type $Mc_2M(H)C^+H_2$, are thought to be less likely on the following grounds.

(i). In the case of M = Pb, it is highly unlikely that an ion containing Pb-H bonds would be as abundant as is the $C_3H_9Pb^+$ ion found in the mass spectra of the lead compounds. The relative abundances and appearance potentials from organolead compounds are consistent with the trends in results from the other compounds including those containing Me₃C-groups.

(ii). Appearance potential measurements on the ion $C_3H_9Si^+$ derived from Me₃Si-CH₂Si(H)Me₂* showed an unusually long "tail" in the ionisation efficiency curve indicative of ions of the same m/e originating from at least two different sources.

(iii). It seems probable that the ionisation potential of the radical Me₂Si(H)CH₂ lies between that of a methyl radical (9.95 eV)²⁴ and a t-butyl radical (7.42 eV)¹, while the value for the radical Me₃Si is probably lower (see Table 1). However, supposing that the lower appearance potential of the ion C₃H₉Si⁺ was due to Me₂Si(H)C⁺H₂ and Me₃Si⁺ appears at some higher energy, (say 0.5 eV higher), then the difference of ~0.5 eV would correspond to the energy required to convert Me₃Si⁺ to Me₂Si(H)⁺CH₂ and/or the difference in any excess energy carried by these ions at their production. This is inconsistent with all the other appearance potential measurements and would produce a value for the silicon-silicon bond dissociation energy in Me₆Si₂ of the order of 0.5 eV higher, *i.e.* ~80 kcal/mole compared with the kinetically-determined⁴ value of 69± 3 kcal/mole. If, however, the lower appearance potential is indeed due to Me₃Si⁺, the results become chemically acceptable.

(iv). Further argument against carbonium ion formation is the identification

^{*} A sample of this compound was kindly supplied by Dr. J. Simmie of this laboratory.

of metastable ions corresponding to elimination reactions of the types shown in eqn. (3); there is independent evidence on this point^{22,23}.

$$C_{3}H_{9}M^{+} \longrightarrow C_{2}H_{7}M^{+} + C_{2}H_{4}$$
(3)

Processes according to equation (3) were established for the compounds Me_4M and Me_6M_2 (M=Si, Ge, Sn) from metastable ion identification. Even in the spectra of methylsilanes $Me_nSiH_{(4-n)}$ $(n=0-4)^{25}$, hydrogen or hydrocarbons are eliminated [*e.g.* eqn. (4)], but silicon-containing molecules or radicals are not obtained.

$$(H_3Si-CH_3)^+ \xrightarrow{-H_2} (H_4CSi)^+ \xrightarrow{-CH_4} Si^+$$
(4)

(v). Finally, in the spectra of the compounds Me_4M and Me_6MM' (M and M' = Si, Ge, Sn, Pb), hydrocarbon ions are relatively insignificant, accounting for 4% or less of the total ion current.

The ion abundances from organometallic compounds containing Me₃C groups show similarities to those from the corresponding tetramethyl compounds¹⁷. For both series of compounds, as the atomic weight of M increases the abundance of the ion Me₃M⁺ decreases, whilst those of Me₂M⁺, MeM⁺, and M⁺, as well as of hydrocarbon ions, increase. Although there is excellent agreement between the spectrum obtained for Me₆C₂ and that quoted in the literature⁹, there is significant disagreement between the spectrum here obtained for Me₃C-PbMe₃ and that reported by Dibeler *et al.*²⁶. There are large discrepancies in the abundance of the parent ion, and of C₃H₁₅Pb⁺, CH₃Pb⁺, Pb⁺, and C₄H₉⁺. Our figures are 1%, 3% 16%, 6%, and 32% respectively, while those obtained by Dibeler *et al.* are 0.03%, 0%, 29%, 23%, and 1%. Dibeler *et al.*²⁶ do not state the inlet temperature and conditions used in their study, but in a previous paper¹⁷ they used 70 eV electrons and source temperatures in the region of 250°. They reported the spectrum of Me₄Pb in both papers and the ion abundances are in very good agreement. Our milder conditions (50 eV electrons, 80° source temperature, and sample held at -23°) may be partly responsible for the differences in spectra.

The assumption may be made that the relative strengths of the metal-metal bonds will be reflected in the relative abundances of the ions containing the intact M-M' bond. The total percentage of such ions is shown in Table 5.

PERCE	PERCENTAGE OF IONS CONTAINING M-M' BONDS								
C-C	Si-Si	Si-Ge	Si-Sn	Ge-Ge	Ge-Sn	Sn-Sn	Pb-Pb		
6	33	29	27	30	25	30	30		
		·							

Clearly, equating the abundance of M-M' containing ions with bond strengths is incorrect, since, for example, it is generally accepted that the C-C-bond dissociation energy in Me_3C-CMe_3 is much greater than D(Pb-Pb) in $Me_3Pb-PbMe_3$. The ion abundances do, however, reflect the overall *rates* of formation and decomposition of

TABLE 5

ions. For example, the molecule Me_6M_2 just after electron impact is converted into the highly energised ion $Me_6M_2^+$ which has adequate energy to decompose by either of the pathways (5a) or (5b).

$$\operatorname{Me}_{6}\operatorname{M}_{2}^{+} \xrightarrow{(a)} \operatorname{Me}_{5}\operatorname{M}_{2}^{+} + \operatorname{Me}_{5} \xrightarrow{(b)} \operatorname{Me}_{3}\operatorname{M}^{+} + \operatorname{Me}_{3} \xrightarrow{(5)}$$

The favoured pathway will depend on the relative rates of cleavage of the M-M' and M-C bonds in the ions. In the case of Me_6Si_2 , it appears that path (b) is more important. In Me_6Pb_2 , apparently path (a) is more likely, and several ions are formed as a result of more than one Pb-C bond cleavage. From Table 4, it is seen that there is a general trend that more species containing M-M' bonds are formed as M-M' changes from C-C to Pb-Pb. The decomposition of ions such as $Me_5M_2^+$, Me_3M^+ , etc., will depend on whether there are further energetically favourable decomposition paths.

The ion abundances shown in Table 3 are in reasonable agreement with those reported for $Me_6Ge_2^{23,27}$, Me_6Si_2 , Me_6Sn_2 , and $Me_3Si-SnMe_3^{27}$; except for the following: from Me_6Sn_2 , Me_3Sn^+ was found in 46% abundance, compared with 36% reported previously²⁷; from $Me_3Si-SnMe_3$, the parent ion, Me_3Si^+ , Me_3Sn^+ , and Me_2Sn^+ were found in abundances 5%, 33%, 5% and 7%, respectively, whereas earlier figures²⁷ are 2%, 40%, 2% and 5% [the different conditions used (70 eV electrons, source temperature 250°²⁷) may, in part, be responsible for the discrepancies].

Ionisation and appearance potentials

In all measurements of appearance potentials, it was assumed that the process of lowest energy producing the ions Me_3M^+ is that of eqn. (6).

$$Me_3M-X \xrightarrow{e} Me_3M^+ + X^*$$
 (X = Me, M'Me₃) (6)

It was also assumed that the ions Me_3M^+ formed in this way have little (< 0.1 eV) or no excess energy. The self-consistency of the results argues in favour of these assumptions. Whilst the ion Me_3M^+ can only arise from Me_4M^+ in the spectra of the tetramethyl compounds, it is possible that this ion might arise not only from the ion $Me_6M_2^{+*}$ but also from ions $Me_{6-n}Me_2^{+}$ for the hexamethyl compounds. Indeed $Me_5M_2^+$ ions are the most abundant M-M' containing species in all cases. However, the consistency of the results, especially those from compounds such as Me_3C -PbMe₃ and Me_6Pb_2 , argues against $Me_{6-n}M_2^+$ ions being major sources of Me_3M^+ ions. In the case of Me_3C -PbMe₃, the ion $Me_5MM'^+$ most probably has the structure Me_3C -Pb⁺Me₂ rather than Me_2C^+ -PbMe₃; the high abundance of the ion PbMe₃^+ (35%, base peak) suggests that its source is not various $Me_{6-n}CPb^+$ species, but Me_6CPb^+ . Furthermore, although metastable species for reaction (7) have been reported²³, metastable peaks corresponding to the formation of Me_3Ge^+ from $Me_5-Ge_5^+$ have not been identified.

$$Me_{3}Ge-GeMe_{3}^{+} \rightarrow Me_{3}Ge^{+} + GeMe_{3}$$
(7)

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The formation of Me_3C^+ ions from the ion $Me_5C_2^+$ is a real process, as demonstrated by identification of the appropriate metastable species. Presumably, the formation of the ion Me_3C^+ from $Me_6C_2^+$ requires less energy. No evidence was found for metastable species corresponding to the decomposition of $Me_{6-n}M_2^+$ ions into Me_3M^+ ions.

The ionisation and appearance potential results obtained by previous workers are shown in Table 6. There is considerable discrepancy among some of the results,

Compound	IP (eV)	AP (eV)Me3M ⁺	Ref.
Me ₃ CCMe ₃		9.79±0.1	3
	9.74 ± 0.1		30
Me ₃ C-SiMe ₃	9.34±0.06	10.53±0.09	5
	(M	e_3C^+ , 11.88)	
Me ₃ C–SnMe ₃		9.50 ± 0.10	8
Me ₃ Si-SiMe ₃	8.79 <u>+</u> 0.08	10.69±0.04	5
		10.0 <u>+</u> 0.1	35
		10.03 <u>+</u> 0.1	28
Me ₃ Ge-GeMe ₃	8.5 ± 0.1	11.3 ± 0.1	23
Me ₃ Sn-SnMe ₃		9.84 <u>+</u> 0.09	7
	$. 8.08 \pm 0.02$	9.85±0.16	8
Me₄C		10.29 <u>+</u> 0.1	3
		10.83 <u>+</u> 0.1	32
	10.35		31
		10.8 ± 0.1	29
Me₄Si	9.8 ±0.15	11.3 ± 0.15	33
	• 9.98 <u>+</u> 0.03	10.63 ± 0.13	5
	9.81 ± 0.1		34
		10.5 ± 0.1	35
		10.5 ± 0.1	28
	11.2 ±0.2	12.0 ± 0.2	23
Me₄Ge	9.2 <u>+</u> 0.2	10.2 ± 0.1	36
	11.2 ± 0.2	11.4 ± 0.2	23
Me ₄ Sn	8.25 ± 0.15	9.9 ±0.15	33
		9.72±0.06	7
		9.7 ±0.2	37
	9.1 ±0.2	10.8 ± 0.2	23
	8.76±0.02	9_72±0.03	8
Me₄Pb	8.0 ± 0.4	8.9 ±0.1	33
	9.3 ± 0.2	10.1 ± 0.1	23

probably due to the fact that different conditions and methods of interpretation of ionisation efficiency curves have been used. However, it is interesting to note that the ionisation potential of Me_4Si obtained by photoelectron spectroscopy³⁴ agrees well with our result.

With regard to the assumption that Me_3M^+ ions are formed with negligible excess kinetic energy, it has been shown that the ion Me_3C^+ derived from Me_6C_2 carries only a very small amount (0.052 eV) of excess energy³⁸. It is interesting to note that although H_3C^+ is known to be formed from $H_3C^-CH_3$ with a large amount

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TABLE 6

 $(\sim 1-2 \text{ eV})^{39}$ of excess energy, the H₃Si⁺ and H₃Ge⁺ ions from H₃Si-GeH₃ are apparently formed with negligible excess energy⁴⁰. Hess *et al.* have reported the appearance potentials of Me₃M⁺ ions from Me₃C-SiMe₃⁵. (We were unable to prepare a pure sample of Me₃CSiMe₃, although several preparative methods were used.) Their value for Me₃C⁺ is high, apparently due to excess energy of the order of 1 eV. As with most ionisation efficiency curves of Me₃M⁺ ions, the relatively long "tails" to the curves makes their interpretation difficult. With the retarding potential difference method, used by Hess *et al.*⁵, it is possible that this is too insensitive. Their values of the appearance potential of Me₃Si⁺ from Me₄Si and Me₆Si₂ are also higher (by 0.7 eV in the case of Me₆Si₂) than the values obtained by Davidson *et al.*³⁵, Haszeldine *et al.*²⁸, and ourselves (Table 4). From "Stevenson's Rule"³, it is to be expected that if any ions are formed with excess kinetic energy, then that ion for which the corresponding radical ionisation potential is the greater will carry the excess energy: *i.e.*, from Me₃C-MMe₃, the ion Me₃C⁺. The self-consistency of our results points to there being negligible excess energy in the ions formed.

CALCULATION OF STANDARD ENTHALPIES OF FORMATION

The appearance potentials listed in Table 4 and the known or estimated values for the gas phase standard enthalpies of formation of Me[•], Me₃C[•], Me₃C⁺, Me₄M, Me₆C₂, Me₆Si₂, and Me₆Sn₂ (Table 7) can be represented by the set of Equations (1)

$$\Delta H_j^0 = \sum_i \left(n_{ij} \Delta H_{f_i}^0 \right) \tag{1}$$

where ΔH_j^0 is the enthalpy change for reactions *j* (*i.e.*, the appearance potentials for the processes:

$$Me_3MM'Me_3 \rightarrow Me_3M' + Me_3M' + e^-$$

and

$$Me_4M \rightarrow Me_3M^+ + Me_1e^-$$
;

or appropriate enthalpies of formation of the above species); $\Delta H_{f_i}^0$ are the standard enthalpies of formation of the molecules, radicals, and ions involved; and n_{ij} are the number of moles of species *i* in reaction *j* (negative for reactants and positive for products). Since equations (1) are overdetermined (31 equations for 27 standard enthalpies of formation) they are more correctly written in the form of equation (2),

$$\delta_j = \Delta H_j^0 - \sum_i (n_{ij} \Delta H_{f_i}^0) \tag{2}$$

where δ_j represents unknown errors associated with the measurements. The best values of $\Delta H_{f_i}^0$ are those which minimize $\Sigma \delta_j \omega_j^2$, where ω_j are weighting factors for the measurements; whence equations (3) are derived.

$$\Delta H_{f_i}^0 \left[\sum_j \left(n_{ij} n_{kj} \omega_j^2 \right) \right] = \sum_j \left(n_{kj} \omega_j^2 \Delta H_j^0 \right)$$
(3)

The weighting factor ω_j was set equal to one for all equations except those corresponding to the "known" enthalpies of formation Me, Me₄C, and Me₆C₂. In the latter

three cases ω_j was set equal to 10 to ensure that the least squares treatment did not modify significantly these accurately known standard enthalpies of formation.

Equations (3) were solved by standard computing techniques using the ICT 1905 computer at this University, to give the standard enthalpies of formation in Table 8. Residuals were calculated from equations (2), and in every case except Me_4Sn , they were found to be less than the uncertainty intervals quoted in Tables 4 and 7. For Me_4Sn the calculated value is 1.5 kcal/mole different from the input literature value, which has an uncertainty interval of 0.9 kcal/mole. The maximum residual was found to be 1.5 kcal/mole, and the average of the absolute values of the residuals was 0.5 kcal/mole.

The values for $D(Me_3M-Me)$, $D(Me_3M-M'Me_3)$, and $\overline{D}(Me_4M)$ (mean bond

TABLE 7

KNOWN OR	ESTIMATED	STANDARD	ENTHALPIES	OF FORMATION	(kcal/mol	e)
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Compound	ΔH_f^0
•CH ₃	34.80±0.1ª
Me₄C	-40.27±0.25 ^b
Me ₃ C·	6.7±1.0°
Me_3C^+	178.3 <u>+</u> 1.0 ^e
Me₄Si	-47.0 ± 6.0^{d}
Me ₄ Ge	-32.0 ± 3.0^{d}
Me₄Sn	-4.8 ± 0.9^{b}
Me₄Pb	32.6 <u>+</u> 0.7 ^b
Me ₆ C ₂	- 53.89±0.5°
Me ₆ Si ₂	-87.0 ± 2.3^{e}
Me ₆ Sn ₂	-6.4 ± 2.4^{b}

^a W. A. Chupka, J. Chem. Phys., 48 (1968) 2337. ^b J. D. Cox and G. Pilcher, Thermochemistry of Organic and Organometallic Compounds, Academic Press, London-New York, 1970. ^c S. W. Benson, Thermochemical Kinetics, John Wiley, New York, 1968. ^d From ref. $b \Delta H_f^o Et_4 Ge(g) = -39.6 \pm 1.6$ kcal/mole and from unpublished rotating bomb studies (by J. B. P.) $\Delta H_f^0 Et_4 Si(g) = -56.9 \pm 4.9$ kcal/mole. The increment in ΔH_f^0 on changing from a methyl to an ethyl group is approximately 1.5 to 2.5 kcal/mole for most organometallic compounds (see ref. 10). The difference between the standard enthalpies of formation of Me₄C(g) and Et₄C(g) is 3.75 kcal/mole per alkyl group (ref. b). It was therefore assumed that the standard enthalpies of formation of Me₄Ge(g) and Me₄Si(g) were respectively 8 and 10 kcal/mole higher than the corresponding ethyl compounds. ^c Unpublished rotating bomb studies (by J. B. P.)

dissociation energy) are given in Table 8, these being derived from the appropriate standard enthalpies of formation. There are certain obvious trends in these dissociation energies, but these are best discussed in terms of the energies of the bonds in the various species. These were derived from the "atomic" heats of formation ($\Delta H_{f_a}^0$), *i.e.*, the enthalpy changes for the processes:

$$Me_4M(g) \rightarrow M(g)+4 C(g)+12 H(g)$$

$$Me_6MM'(g) \rightarrow M(g)+M'(g)+6 C(g)+18 H(g)$$

$$Me_3M(g) \rightarrow M(g)+3 C(g)+9 H(g)$$

$$Me_3M^+(g) \rightarrow M^+(g)+3 C(g)+9 H(g)$$

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DERIVED STANDARD ENTHALPIES (kcal/mole) OF FORMATION AND BOND S

Compound	ΔH_f^0	$-\Delta H_{fa}^{0 a}$	D	Б	E	Bond
CH ₃ .	34.80					
Me₄C	-40.27	1520.0	81.9	87.6	82.1	C-C
Me ₃ C·	6.80	1145.7			84.0	· C-C
Me ₃ C ⁺	178.20	1234.1			113.5	C+-C
Me₄Si	-48.25	1465.5	74.4	74.0	68.5	Si-C
Me ₃ Si	- 8.63	1098.6			68.3	Si–C
Me ₃ Si ⁺	158.56	1119.4			75.2	Si ⁺ -C
Me₄Ge	- 32.00	1431.0	69.0	65.4	59.9	Ge-C
Me ₃ Ge•	2.25	1069.6			58.6	Ge-C
Me ₃ Ge ⁺	164.99	1088.5			64.9	Ge ⁺ C
Me ₄ Sn		1384.2	65.4	53.6	48.1	Sn-C
Me ₃ Sn•	27.22	1026.4			44.2	Sn-C
Me ₃ Sn ⁺	184.25	1038.7			48.3	Sn+-C
Me ₄ Pb	32.60	1323.0	48.8	38.4	32.9	РЬ-С
Me ₃ Pb [•]	46.66	981.7			29.3	Pb-C
Me ₃ Pb ⁺	200.07	999.3			35.2	Pb⁺–C
Me ₆ C ₂	- 53.89	2358.9	67.5		78.9	C–C
Me ₆ Si ₂	- 86.38	2266.4	69.1		68.0	Si-Si
Me ₆ Ge ₂	-62.46	2206.1	67.0		59.3	GeGe
Me ₆ Sn ₂	-7.12	2114.3	61.6		38.3	Sn–Sn
Me ₆ Pb ₂	38.71	2018.1	54.6		33.3	Pb-Pb
Me ₃ CGeMe ₃	- 55.65	2280.0	64.7		66.6	C-Ge
Me ₃ CSnMe ₃	24.89	2231.0	58.9		53.0	C–Sn
Me ₃ СРЬМе ₃	6.92	2174.0	46.5		41.6	C-Pb
Me ₃ SiGeMe ₃	-74.11	2235.9	67.7		63.3	Si-Ge
Me ₃ SiSnMe ₃	- 49.69	2193.3	68.3		56.1	Si-Sn
Me ₃ GeSnMe ₃	- 39.65	2165.1	69.1		. 53.7	Ge-Sn

^a The atomic heats of formation were calculated using the following data derived from ref. b of Table 7: $\Delta H_f^0 H(g) = 52.10$, C(g) = 170.90, Si(g) = 108.4, Ge(g) = 90.2, Sn(g) = 72.0, Pb(g) = 46.8 kcal/mole; and, from C. E. Moore, *Nat. Bur. Stand. Circ.* 467, Vol. 1, 1949, Vol. 2, 1952 and Vol. 3, 1958: $\Delta H_f^0 C^+(g) = 430.67$, $Si^+(g) = 296.33$, $Ge^+(g) = 271.93$, $Sn^+(g) = 241.32$, and $Pb^+(g) = 217.80$ kcal/mole.

The C-H bond energy was assumed to be 99.3 kcal/mole (as in CH₄), whence the values of E(M-CH) and $E(M^+-CH_3)$ were derived. For the species Me₃MM'Me₃ it was assumed that the values of $E(M-CH_3)$ were the same as in the corresponding compounds Me₄M and Me₄M'. Thus the quoted bond energy refers only to the central M-M'-bond where M and M' may be C, Si, Ge, Sn or Pb.

Trends in bond energy terms

The reliability of the new thermochemical data summarised in Table 8 may be gauged by the following criteria: (i) the small residuals: these attest to the mutual compatibility of the data in the least squares treatment; and (ii) they are in satisfactory agreement with literature values for $D(Me_3Si-Me)^4$, $D(Me_3Si-SiMe_3)^{35}$, $D(Me_3Sn-Me)$, $D(Me_3C-SnMe_3)$, and $D(Me_3Sn-SnMe_3)^{40}$. Because of the present state of Group IV organometallic calorimetry, there is some doubt concerning *absolute* values of ΔH_f^0 , in particular of Me_4Si and Me_4Ge ; however, the values of D are independent of the chosen value of ΔH_f^0 of $Me_4M(g)$.

The trends in E determine trends in D and \overline{D} , while D and \overline{D} are determined

by strengths of bonds in both parent molecules and radicals derived therefrom. It is convenient, therefore to comment below upon trends in terms of values of E. The following discussion relates to changes in E in the various species and should be read in conjunction with Table 8.

First considered are C-C bond strengths. The increase in E(C-C) in Me₃C (84.0 kcal/mole) compared with Me₄C (82.1 kcal/mole) is attributed to a hyperconjugative effect. The very large increase in proceeding further to Me₃C⁺ (113.4 kcal/mole) is reflected in the difference in first ionisation potential of C (11.26 eV) and Me₃C (7.4 eV). Hyperconjugation is most effective with an *empty* p_{π} orbital on the central carbon atom giving rise to canonical forms such as:



The suggestion that the central C-C bond in Me_3C-CMe_3 is weaker than $E(Me_3C-Me)$ by about 3 kcal/mole is attributed to steric strain in the former. However, to some extent this is an artefact, because the total effect is arbitrarily assigned solely to the central C-C bond in hexamethylethane.

When similar trends are examined for the Group IV elements other than carbon, the picture is clearly somewhat altered. The trends in bond strengths in comparing Me_4M with Me_3M^{\bullet} show an increase in the order Si < Ge < Sn \approx Pb. It appears that for the radicals Me_3Si and Me_3Ge there is no particular gain in M-C stabilisation compared with Me_4M (in contrast to the Me_3C^{\bullet} situation) and this is consistent with the fact that these radicals differ from alkyl radicals in being pyramidal (C_{3v}) rather than having D_{3h} symmetry. As yet, comparable information on tin and lead radicals is not available, but perhaps these will prove to resemble those of silicon. In proceeding further to consider $\overline{E}(M-C)$ in Me_3M^+ , there is clearly significant stabilisation compared with Me_4M or Me_3M^{\bullet} , but the effect is far less pronounced for Si, Ge, Sn, or Pb than for C. This suggests that for the heavier Group IVB elements, the hyperconjugative effect in Me_3M^+ is much less important than when M is C.

A comparison of E(M-C) in Me₃M-CMe₃ and Me₃M-Me leads to the rather curious conclusion that the M-C bonds in the former compounds are stronger than in the tetramethyls. This effect is most pronounced for Pb, with $E(Me_3Pb-CMe_3)$ 41.6 kcal/mole compared with $E(Me_3Pb-Me)$ 32.9 kcal/mole. One aspect of this effect is not unreasonable: namely, that a bulky t-butyl group will be most comfortably accommodated on the largest available central atom (Pb).

COMPARISON OF $E(M-M')$ with $\frac{1}{2}[E(M-M) + E(M'-M')]$		
Compound	E(M-M')	$\frac{1}{2}[E(M-M) + E(M'-M')]$
MM'		
C-Ge	66.6	69.1
C-Sn	53.0	58.6
С-Рь	41.6	56.1
Si-Ge	63.3	63.7
Si-Sn	56.1	53.2
Ge-Sn	53.7	48.8

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TABLE 9

Additionally, it is of interest to compare (Table 9) bond energies in heteronuclear pairs $Me_3M-M'Me_3$ with those calculated if the appropriate redistribution reactions from homonuclear partners were thermoneutral. It is clear that only if one member of a heteronuclear pair is carbon such compounds are less stable than their symmetrical products of disproportionation.

Finally, we note that the bond energy terms for carbon to Group IV element bonds E(C-M') decrease in the series,

$$(C-C) > (C-Si) > (C-Ge) > (C-Sn) > (C-Pb)$$

as might be expected on grounds of compatibility of C-M' orbitals. It is interesting to compare this with a similar series for (N-M') bonds in Me₃M'-NR₂ compounds⁴¹,

$$(N-C) < (N-Si) > (N-Ge) > (N-Sn)$$

The (N-M') series was rationalised in terms of the importance of π bonding from N to M', which appears to be especially significant at silicon.

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